



Atty. Dkt. No. 083847-0198

*DDW*

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant: Crocker et al.

Title: Nanometer-Scale Engineered Structures, Methods and Apparatus  
for Fabrication thereof, and Applications to Mask Repair,  
Enhancement, and Fabrication

Appl. No.: 10/689,547

Filing Date: 10/21/2003

Examiner: Ruggles

Art Unit: 1756

**RESPONSE TO NOTICE OF NON-COMPLIANT AMENDMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

The Applicants respectfully respond to the Notice of Non-Compliant Amendment,  
mailed on December 4, 2006.

The amendments to the abstract begin on page 2.